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FIRST NAMED INVENTOR ATTORNEY DOCKET NO. IM32/0512 **EXAMINER** WILLIAM B KEMPLER RAMOS, V PEREZ TEXAS INSTRUMENTS INCORPORATED P 0 B0X 655474 MS 3999 ART UNIT PAPER NUMBER DALLAS TX 75265

**DATE MAILED:** 

05/12/99

Please find below and/or attached an Office communication concerning this application or proceeding.

**Commissioner of Patents and Trademarks** 

	<del>*</del>
Office Action Summary	Application No. O9/019087 Enomoto et al.
	Examiner Vanessa Pérez-Rano 1765
—The MAILING DATE of this communication appears on the cover sheet beneath the correspondence address—	
Period for Response	3
A SHORTENED STATUTORY PERIOD FOR RESPONSE IS SET MAILING DATE OF THIS COMMUNICATION.	T TO EXPIRE MONTH(S) FROM THE
from the mailing date of this communication.  - If the period for response specified above is less than thirty (30) days, a  - If NO period for response is specified above, such period shall, by defau	response within the statutory minimum of thirty (30) days will be considered timely. It, expire SIX (6) MONTHS from the mailing date of this communication . statute, cause the application to become ABANDONED (35 U.S.C. § 133).
Status	2
$\boxtimes$ Responsive to communication(s) filed on $2-5-98$	<u> </u>
☐ This action is FINAL.	
<ul> <li>Since this application is in condition for allowance except fo accordance with the practice under Ex parte Quayle, 1935</li> </ul>	r formal matters, <b>prosecution as to the merits is closed</b> in C.D. 1 1; 453 O.G. 213.
Disposition of Claims	
<b>⊗</b> Claim(s) l —	is/are pending in the application.
Of the above claim(s)	is/are withdrawn from consideration.
□ Claim(s)	is/are allowed.
Claim(s)   -	is/are rejected.
☐ Claim(s)	is/are objected to.
☐ Claim(s)	are subject to restriction or election requirement.
Application Papers	·
See the attached Notice of Draftsperson's Patent Drawing I	
☐ The proposed drawing correction, filed on	
☐ The drawing(s) filed on is/are objected	d to by the Examiner.
☐ The specification is objected to by the Examiner.	
☐ The oath or declaration is objected to by the Examiner.	
Priority under 35 U.S.C. § 119 (a)-(d)	
<ul> <li>         □ Acknowledgment is made of a claim for foreign priority und         □ All □ Some*</li> <li>         □ None of the CERTIFIED copies of the certification.     </li> <li>         □ received in Application No. (Series Code/Serial Number)     </li> </ul>	e priority documents have been
$\ \square$ received in this national stage application from the Intern	national Bureau (PCT Rule 1 7.2(a)).
*Certified copies not received:	·
Attachment(s)	
□ Information Disclosure Statement(s), PTO-1449, Paper No	s) □ Interview Summary, PTO-413
➤ Notice of References Cited, PTO-892	☐ Notice of Informal Patent Application, PTO-152
> Notice of Draftsperson's Patent Drawing Review, PTO-948	☐ Other
Office Action Summary	

U. S. Patent and Trademark Office PTO-328 (Rev. 3-97)

Part of Paper No.

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### **DETAILED ACTION**

# Specification

1. The abstract of the disclosure does not commence on a separate sheet in accordance with 37 CFR 1.52(b)(1). A new abstract of the disclosure is required and must be presented on a separate sheet, apart from any other text.

# Claim Rejections - 35 USC § 112

- 2. The following is a quotation of the second paragraph of 35 U.S.C. 112:
  - The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 3. Claims 1-3 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

The statement "removing the second mask film such that it is left on the side walls of the second mask film is formed on the side walls of the trenches" in Claim 1, and similar statements in Claims 2 and 3 are vague and indefinite by using improper grammar.

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# Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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5. Claims 1-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tsuji (U.S.5,514,625).

In regard to claims 1-3, Tsuji teaches a method of manufacturing a semiconductor device comprising: forming an insulating film over a substrate (col. 5, lines 7-10), forming a first mask on said insulating film (col. 5, line 24) and forming a resist film on the first mask film (col. 5, line 18). This resist film serves as a mask during the etching process (col. 5, lines 32-35) to form an opening (col. 5, lines 29-31), which is followed by the formation of trenches on said insulating film (col. 5, lines 26-28). Furthermore, Tsuji teaches the formation of a second mask film (col. 5, line 46) and its use as an etching mask during the formation of connecting holes (col. 5, lines 44-50). Tsuji also teaches the formation of a wiring layer by burying an electroconductive material in the trenches (col. 7, lines 19-23).

Unlike the claimed invention, Tsuji does not disclose the removal of the first and second mask films.

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It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify Tsuji by removing the first and second mask films during the semiconductor

manufacturing process in anticipation of an expected result.

In regard to claims 4, 7 and 9, these claims differ from Tsuji by specifying various

materials for the insulating film. It would have been obvious to one of ordinary skill in the art at

the time the invention was made to modify Tsuji by using different materials to form the insulating

film in anticipation of an expected result, since the use of such different materials is well known in

the art of semiconductor manufacturing.

In regard to claims 5-6, 8 and 10-11, these claims differ from Tsuji by specifying that the

holes are in contact with the lower electrodes in the capacitors of the memory cells, and by

disclosing that capacitors are set for storing information. It is the Examiner's position that these

are condictions well known in the semiconductor art, and that it would have been obvious to

modify Tsuji by disclosing the above-mentioned information.

6. Any inquiry concerning this communication or earlier communications from the examiner

should be directed to Vanessa Perez-Ramos whose telephone number is (703) 306-5510.

**VPR** 

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May 7, 1999

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